



MACHAKOS UNIVERSITY

University Examinations for 2017/2018

SCHOOL OF ENGINEERING AND TECHNOLOGY

DEPARTMENT OF COMPUTING AND INFORMATION TECHNOLOGY

FIRST YEAR FIRST SEMESTER EXAMINATION FOR BACHELOR OF
SCIENCE (MATHEMATICS AND COMPUTER SCIENCE)

SMA 130: INTRODUCTION TO ELECTRONICS

DATE: 20/12/2017

TIME: 8:30 – 10:30 AM

INSTRUCTIONS: Answer Question One and Any Other Two Questions

Physical constants

Electronic charge, $e = 1.6 \times 10^{-19} \text{C}$

Mass of an electron, $m_e = 9.11 \times 10^{-31} \text{kg}$

Planck's Constant, $h = 6.625 \times 10^{-34} \text{JS}$

Permittivity of free space, $\epsilon_0 = 8.854 \times 10^{-12} \text{FM}^{-1}$

Permeability of free space, $\mu_0 = 4\pi \times 10^{-7} \text{Hm}^{-1}$

Electron mobility $\mu_e = 0.38 \text{m}^2 \text{v}^{-1} \text{s}^{-1}$ (intrinsic Ge)

Hole mobility, $\mu_n = 0.18 \text{m}^2 \text{v}^{-1} \text{s}^{-1}$ (intrinsic Ge)

Boltzmann's constant, $k_B = 1.38 \times 10^{-23} \text{JK}^{-1}$

Rydberg constant, $R_H = 1.1 \times 10^7 \text{m}^{-1}$

Electron volt (eV) $= 1.6 \times 10^{-19} \text{J}$

Intrinsic carrier density for Germanium , $n_i = 2.5 \times 10^{19} \text{m}^{-3}$

Intrinsic carrier density for silicon , $n_s = 1.5 \times 10^{16} \text{m}^{-3}$ Z for hydrogen =1

Density of Germanium atoms density= 4.2×10^{28} atoms / m^3

QUESTION ONE (20 MARKS)

- a) i State the successes of the Bohr's Atomic model (2 marks)
- ii Explain the meaning of the Valence band (4 marks)
- iii Given that the distribution of electronics according to Fermi-Dirac's statistics into the available energy state is given by
- $$P(E) = \frac{1}{1 + e^{(E - E_F)/KT}}$$
- Explain the case of $E = E_F$ (3 marks)
- b) i Mobilities of electrons and holes in a sample of intrinsic Germanium are $0.36 \text{m}^2 \text{V}^{-1} \text{s}^{-1}$ and $0.17 \text{m}^2 \text{V}^{-1} \text{s}^{-1}$ respectively .If the electron and hole density are each equal to $2.5 \times 10^{19} \text{m}^{-3}$, calculate the sample conductivity (4 marks)
- ii) Explain how the depletion layer is formed in a P-N junction (3 marks)
- c) i Differentiate between Forward and reverse biasing of a PN junction (1 mark)
- ii Explain the meaning of the term Hall effect as used in semiconductors (1 mark)
- iii Write down the disadvantages of Tunnel diodes (1 mark)
- iv Draw the equivalent circuit of a properly biased PNP transistor (2 marks)
- d) i Explain the common base configuration (1 mark)
- ii The following readings were obtained from transistor connected in common Base configuration : $I_E = 2 \text{mA}$ and $I_B = 20 \mu\text{A}$. Compute the values of α and I_C (3 marks)
- iii Explain how the constant – current transfer characteristics are obtained (1 mark)
- e) i Write down the method used in analyzing transistor circuits easily and rapidly (1 mark)
- ii Explain the meaning of acronym 'FET' and write down the two types of FET'S (1 mark)
- iii Explain the function of the following in FETS, source, Drain, Gates and Channel

- iv FETS can be used in almost every application in which BJT's can be used .
However they have certain application which are exclusive to them. Give any
four of their uses (2 marks)

QUESTION TWO (20 MARKS)

- a) State Bohr's postulates of the atomic Models (3 marks)
- b) Show that the velocity of electrons around the nucleus in the n^{th} orbit is given by

$$V = \frac{ze^2}{2E_0 nh}$$

Where the symbols have their usual meaning (5 marks)

- c) Show the kinetic energy of the revolving electrons in the n^{th} orbit of the Bohr's atom is
given by $ke = \frac{mz^2e^4}{8E_0^2 n^2 h^2}$

Evaluate the ionization energy for hydrogen atom ($n=1$) (6 marks)

- d) Applying the Fermi-Dirac statistics for the distribution of electrons into the available
energy states, show that an intrinsic semi-conductor, the Fermi-level lies midway
between the conduction band and the valence band (6 marks)

QUESTION THREE (20 MARKS)

- a) Explain how orbital quantum number, l is used for the following
- Helps to distinguish between different sub-orbits (2 marks)
 - Helps to determine the shape of different sub-orbits (2 marks)
- b) Deduce an expression for the electrical conductivity of an intrinsic semiconductor
(5 marks)
- c) Explain, in terms of the energy band theory, what happens when a donor impurity is
added into an intrinsic semiconductor (3 marks)
- d) A potential difference of 10V is applied longitudinally to a rectangular specimen of an
intrinsic Germanium of length 2.5cm, width 0.4cm and thickness 0.15cm .Calculate at
room temperature
- Electron and hole velocities (3 marks)
 - The total current in the specimen (2 marks)

- e) A specimen of pure Germanium at 300⁰k has a density charge carrier of $2.5 \times 10^{19} \text{m}^{-3}$. It is doped with donor impurity atoms for every 10^{16} atoms of Germanium. All impurity atoms may be supposed to be ionized. Find the resistivity of the doped Germanium (3 marks)

QUESTION FOUR (20 MARKS)

- a) An N-type sample of Germanium contains $N_a = 3.0 \times 10^{18} \text{Cm}^{-3}$ and $N_d = 10^{16} \text{Cm}^{-3}$. A junction is formed by alloying with indium. Assuming that N_a in region are equal to N_a at the n the alloying temperature
- Calculate the Fermi –level position at 300⁰k in the p- and N- region (4 marks)
 - Draw the equilibrium band diagram for the function and determine the barrier voltage from it (3 marks)
 - Calculate the barrier voltage from the barrier voltage equation and comment on the results obtained in (ii) and (iii) (4 marks)
 - If V is the voltage applied in the forward direction explain how this affects the depletion layer (2 marks)
- b) Deduce the expression for the Boltzmann-Diode equation (7 marks)

QUESTION FIVE (20 MARKS)

- Write down the application of the Hall Effect (2 marks)
- State the advantages of transistor over vacuum tubes (3 marks)
- Draw the common base (CB) test circuit used for the study of forward current voltage characteristics of a PNP transistor. Explain briefly (5 marks)
- Show that for a properly biased transistor that $\alpha = \frac{\beta}{1+\beta}$ where symbols have their usual meaning. (4 marks)
- Sketch a well labeled JFET drain characteristics and explain the main features present. (6 marks)